



US 20130241916A1

(19) **United States**

(12) **Patent Application Publication**
Takasugi et al.

(10) **Pub. No.: US 2013/0241916 A1**
(43) **Pub. Date: Sep. 19, 2013**

(54) **VOLTAGE COMPENSATION TYPE PIXEL CIRCUIT OF ACTIVE MATRIX ORGANIC LIGHT EMITTING DIODE DISPLAY DEVICE**

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(21) Appl. No.: **13/889,903**

(22) Filed: **May 8, 2013**

Related U.S. Application Data

(62) Division of application No. 13/110,593, filed on May 18, 2011, now Pat. No. 8,462,086.

(30) **Foreign Application Priority Data**

May 18, 2010 (KR) 10-2010-0046610

Publication Classification

(51) **Int. Cl.**
G09G 3/32 (2006.01)

(52) **U.S. Cl.**

CPC **G09G 3/3291** (2013.01)
USPC 345/212; 345/76

(57) **ABSTRACT**

A voltage compensation type pixel circuit of an AMOLED display device includes a driving transistor serially connected to a light emitting element between high-potential and low-potential power lines to drive the light emitting element in response to a voltage supplied to a first node, a first program transistor for supplying a data voltage of a data line to a second node in response to a scan signal of a scan line, a second program transistor for supplying a reference voltage from a reference voltage supply line to the first node in response to the scan signal of the scan line, a merge transistor for connecting the first and second nodes in response to a merge signal of a merge line, a storage capacitor connected between a third node and the second node interposed between the driving transistor and the light emitting element to store a voltage which corresponds to the data voltage in which the threshold voltage is compensated, and first and second reset transistors for initializing at least two of the first, second, and third nodes to an initialization voltage of an initialization voltage line in response to a reset signal of a reset line.

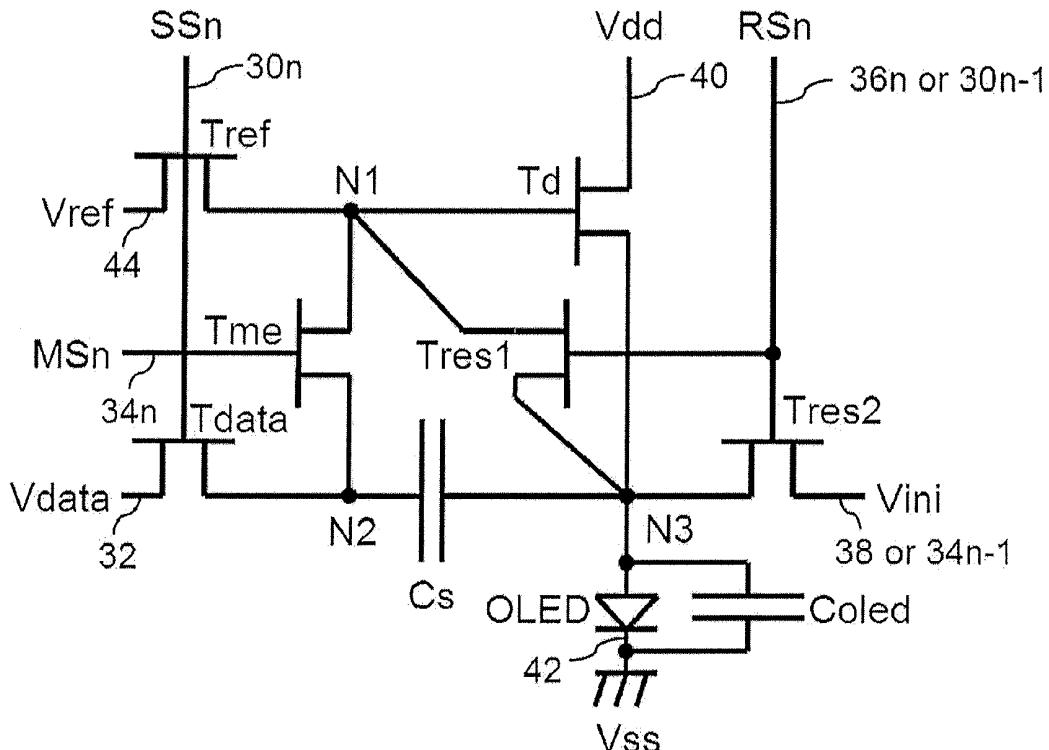


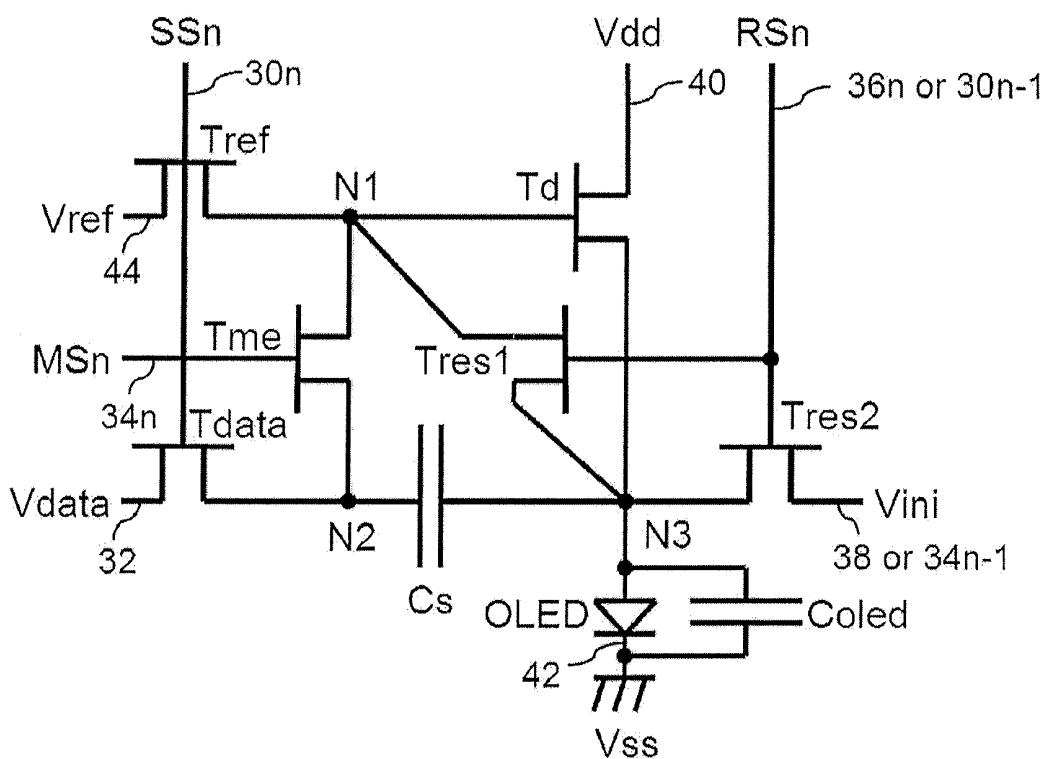
FIG. 1

FIG. 2

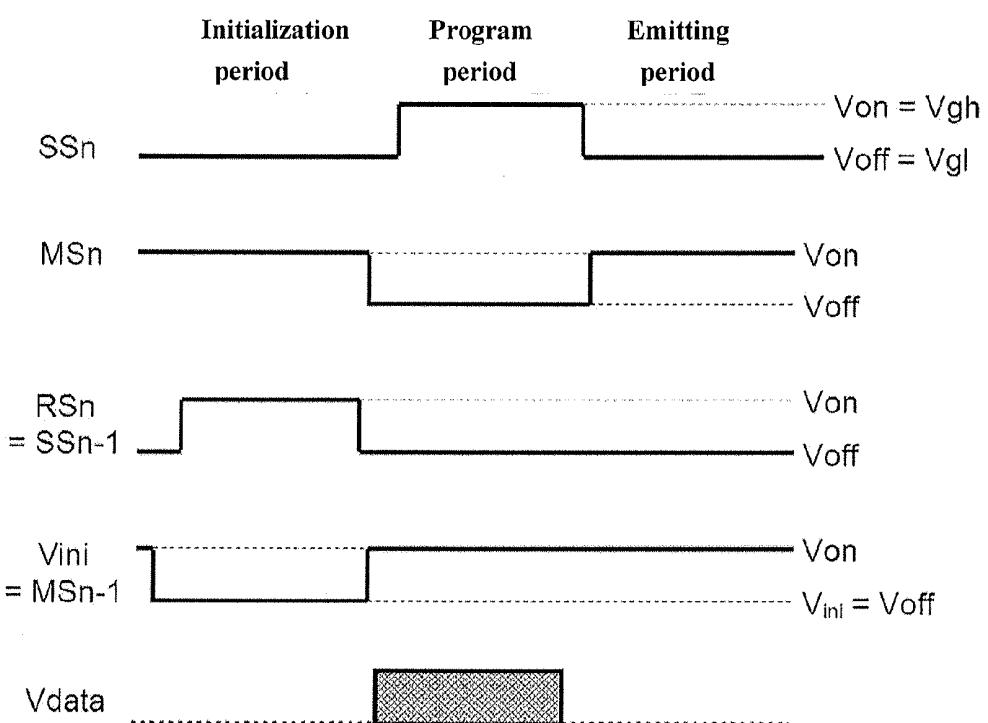


FIG. 3

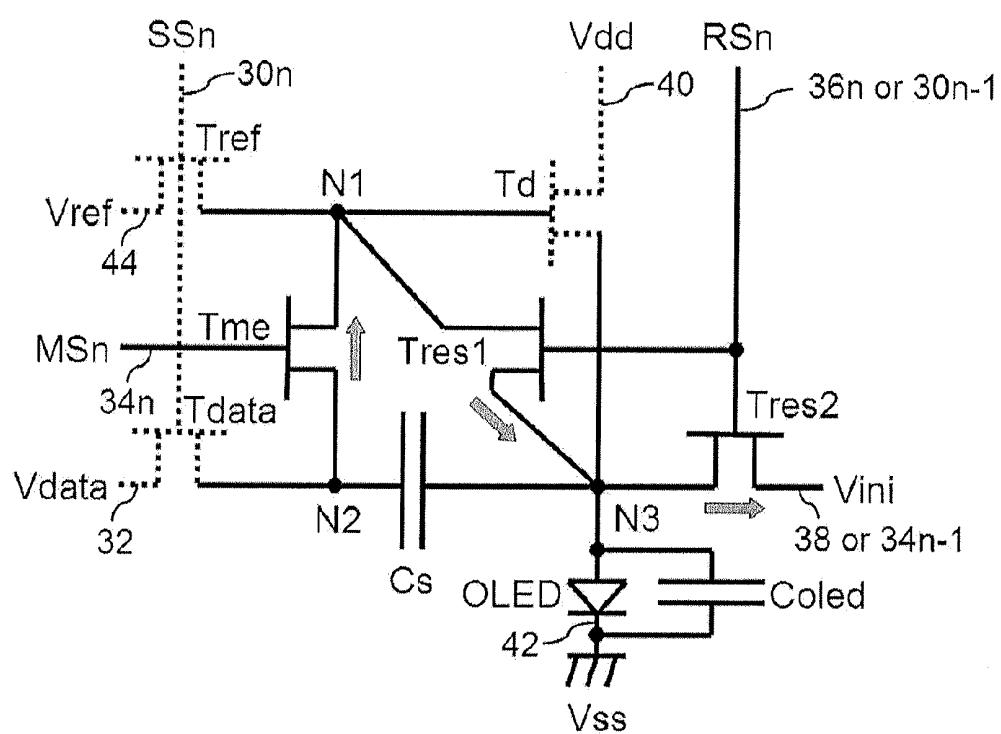


FIG. 4

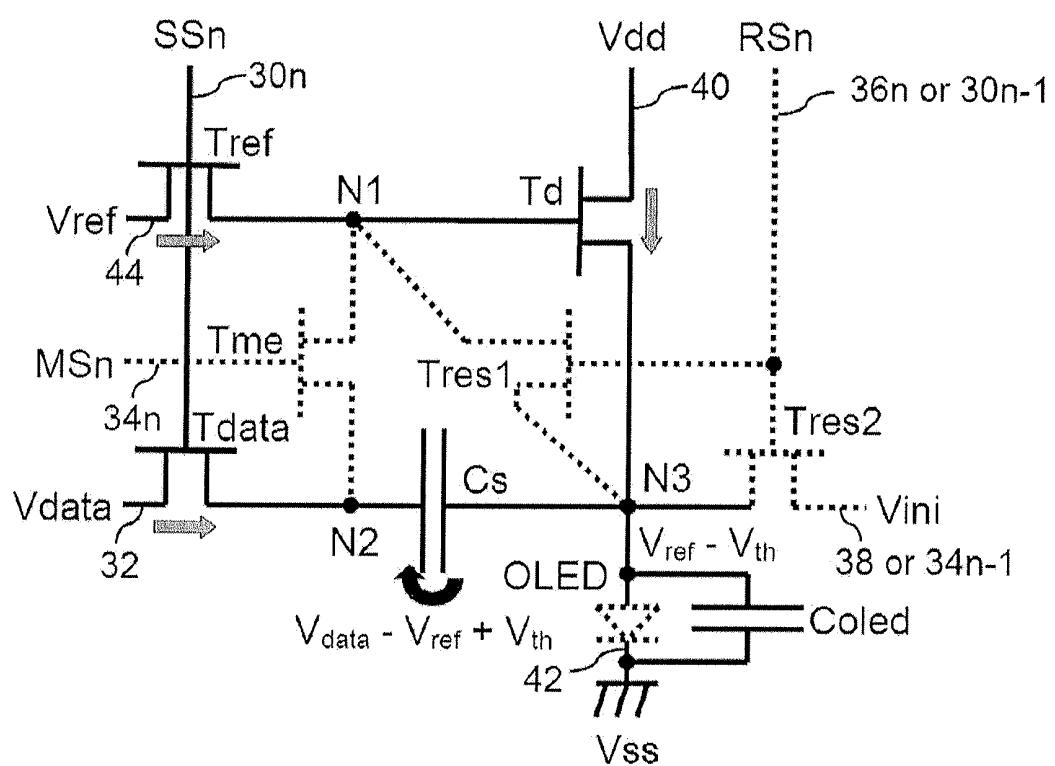


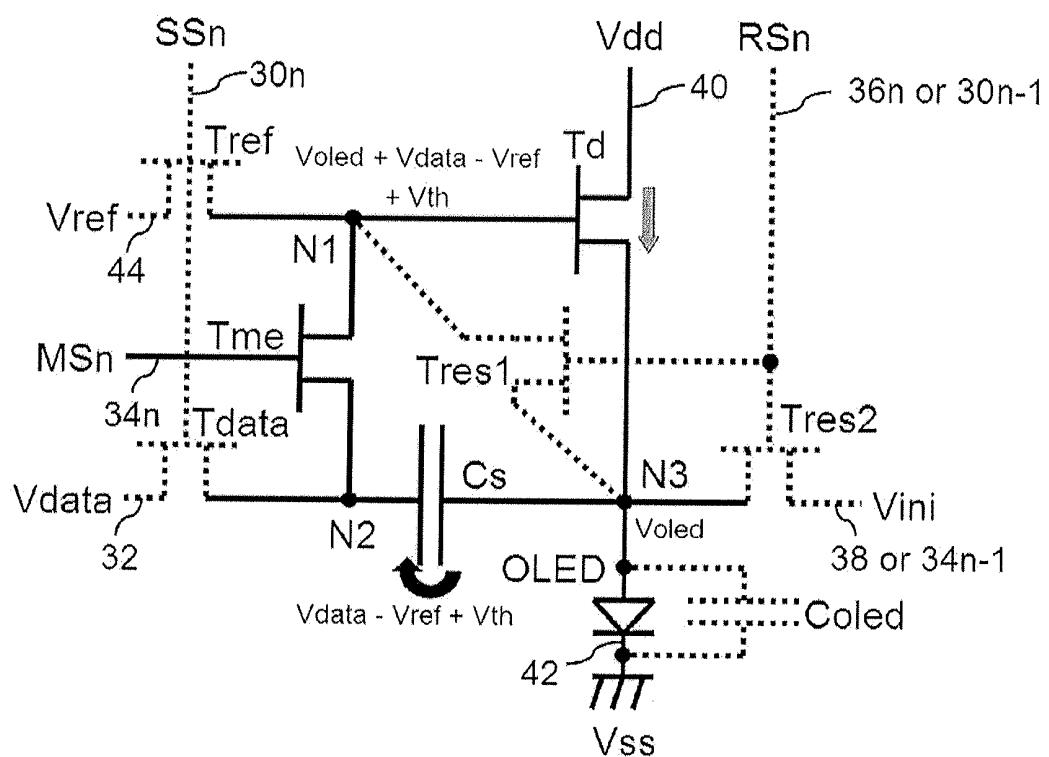
FIG. 5

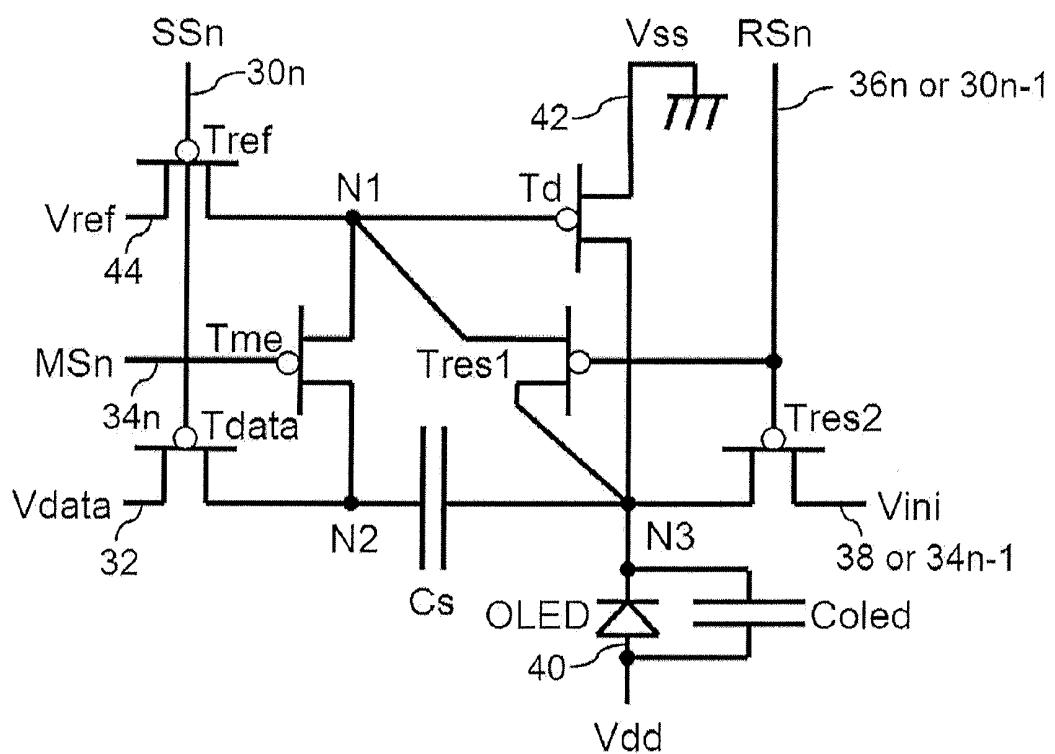
FIG. 6

FIG. 7

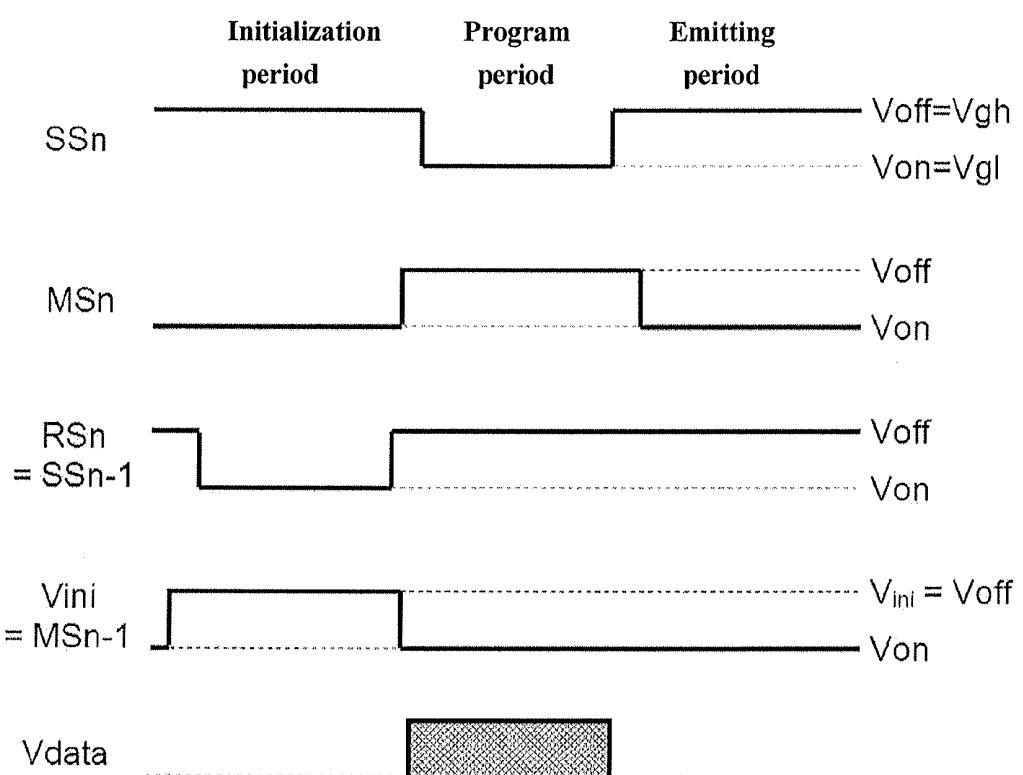


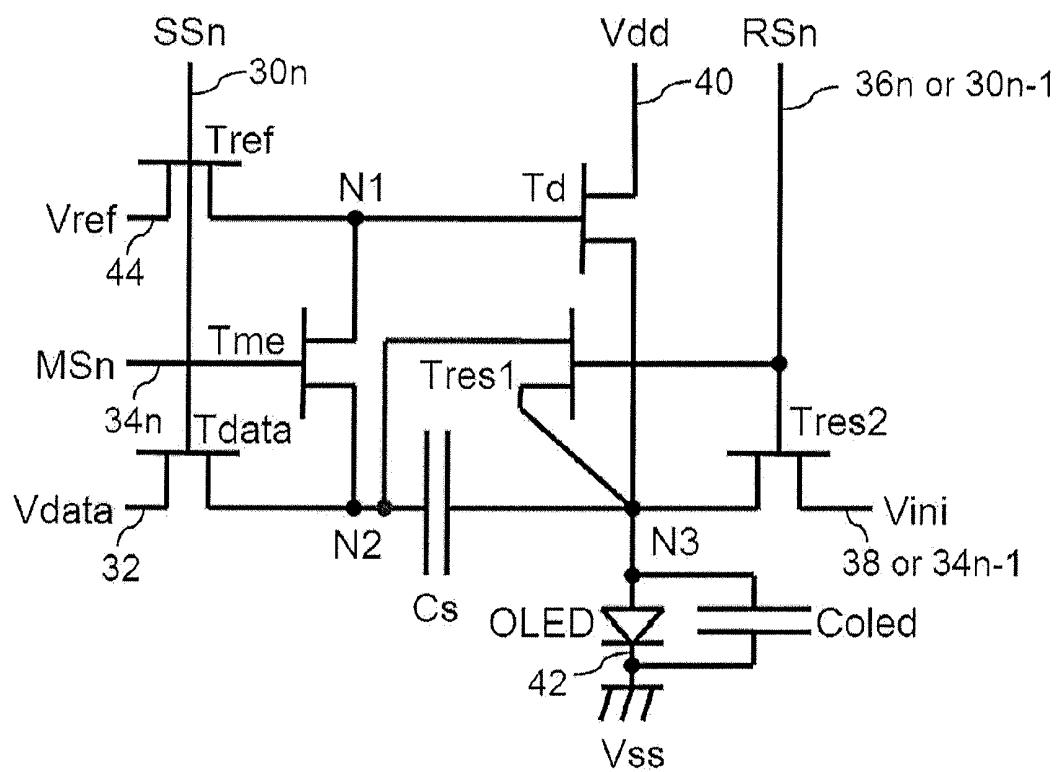
FIG. 8

FIG. 9

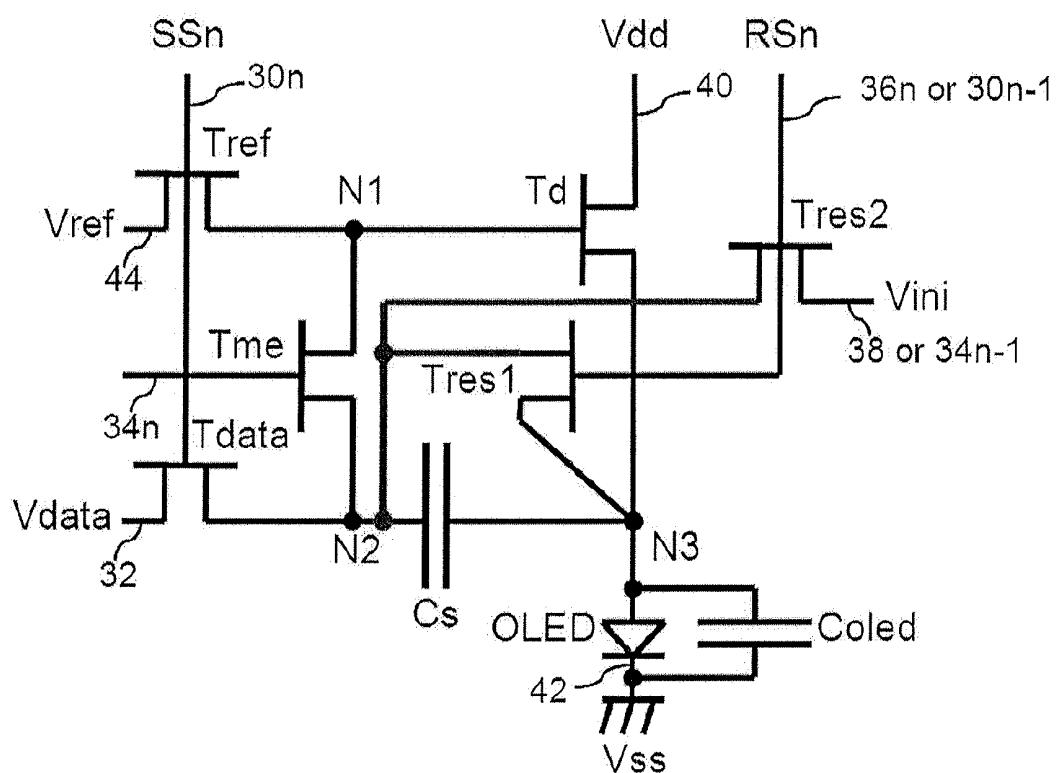


FIG. 10

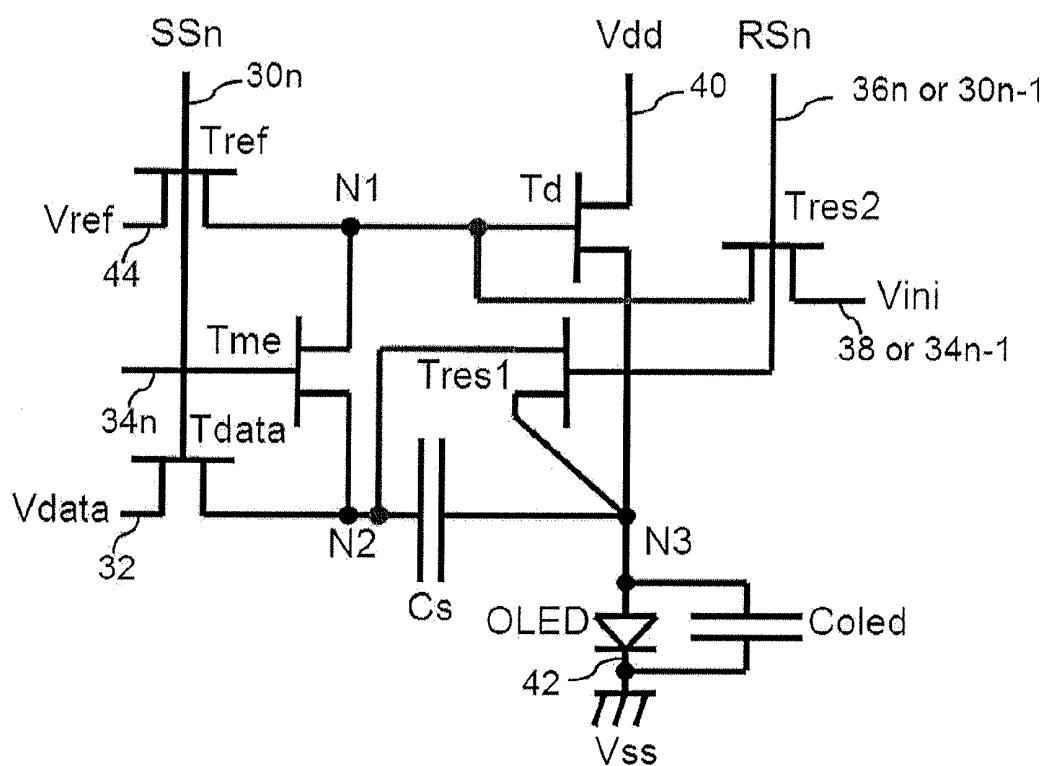


FIG. 11

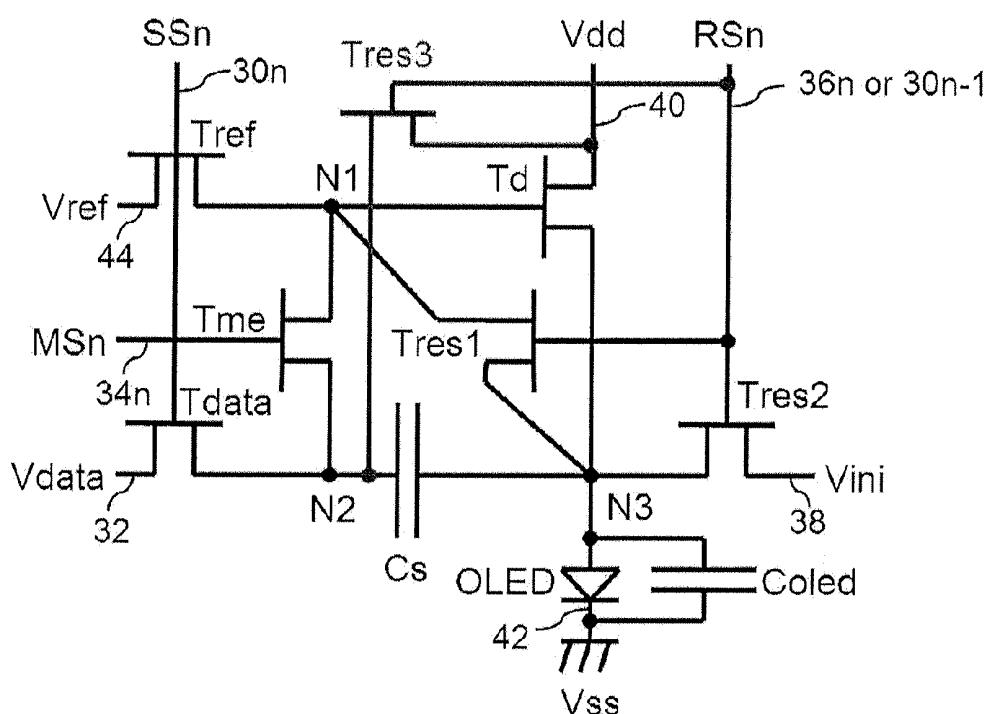


FIG. 12

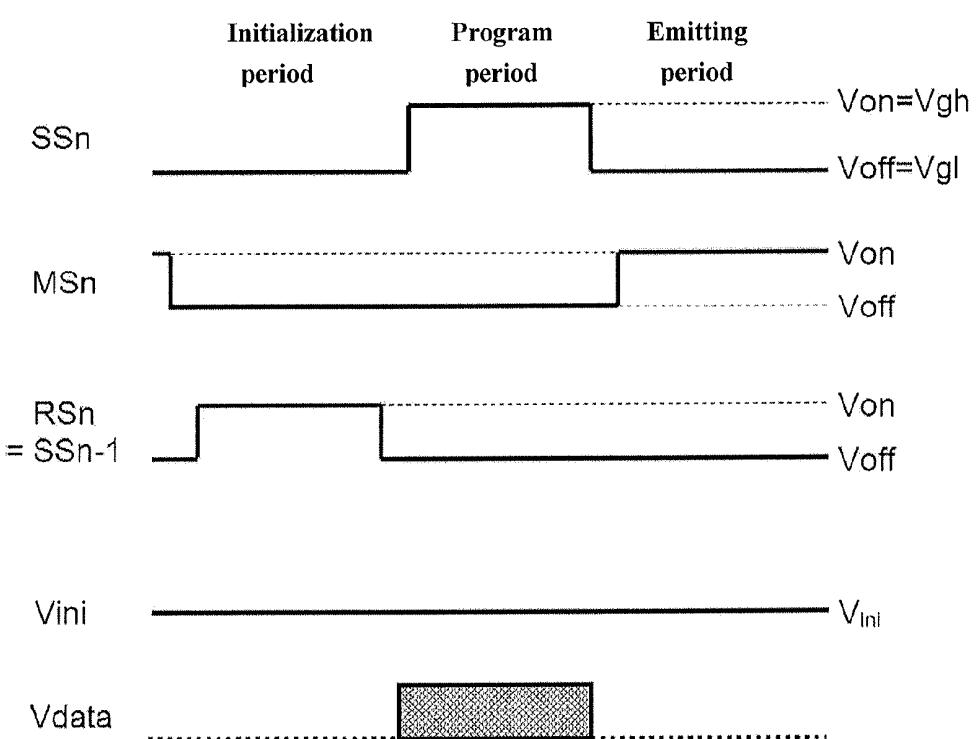
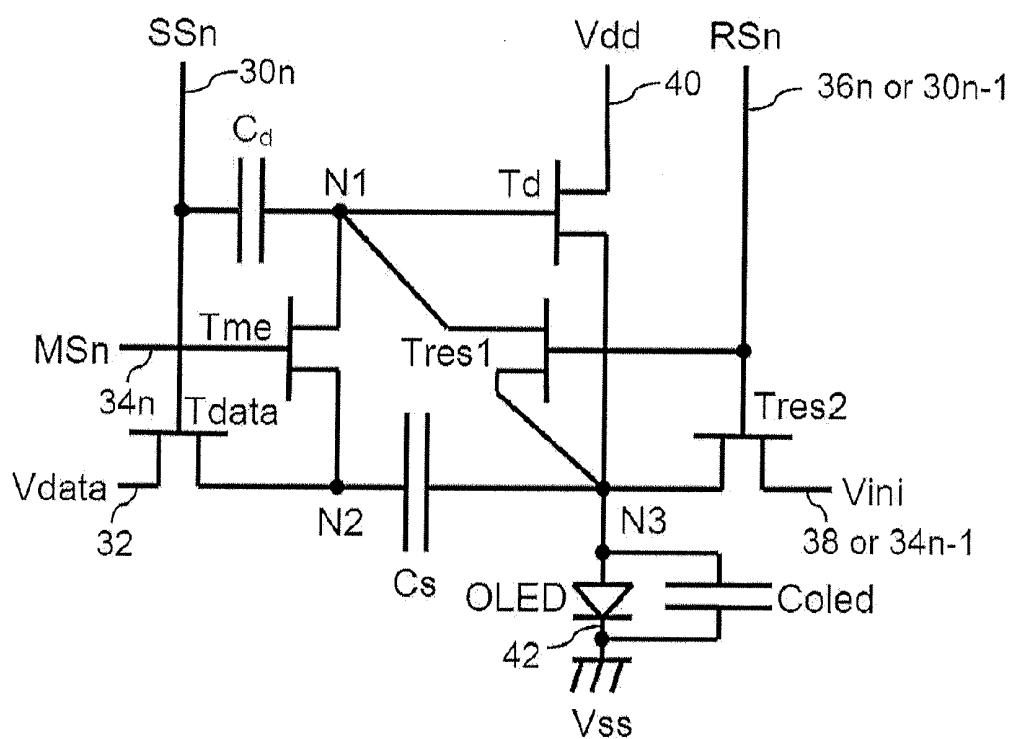


FIG. 13



VOLTAGE COMPENSATION TYPE PIXEL CIRCUIT OF ACTIVE MATRIX ORGANIC LIGHT EMITTING DIODE DISPLAY DEVICE

[0001] The present patent document is a divisional of U.S. patent application Ser. No. 13/110,593, filed May 18, 2011, which claims priority to Korean Patent Application No. 10-2010-0046610 filed in Korea on May 18, 2010.

BACKGROUND

[0002] 1. Field of the Invention

[0003] The present disclosure relates to an Active Matrix Organic Light Emitting Diode (AMOLED) display device, and more particularly, to a voltage compensation type pixel circuit of an AMOLED display device, which can compensate for a positive threshold voltage and a negative threshold voltage and enables a driving transistor to always operate in a saturation region.

[0004] 2. Discussion of the Related Art

[0005] An AMOLED display device is a self-emitting device to emit light through an organic light emitting layer by electron-hole recombination. The AMOLED display device has high luminance and a low driving voltage and can have an ultra-slim size, thereby being expected as a next-generation display device.

[0006] Each of a plurality of circuits constituting an AMOLED display device includes a light emitting element comprised of an organic light emitting layer between an anode and a cathode, and a pixel circuit for independently driving the light emitting element. The pixel circuit may be classified into a voltage-type pixel circuit and a current-type pixel circuit. Since the voltage-type pixel circuit has a simpler external driving circuit than the current-type pixel circuit and is suitable for a high-speed operation, it is well suited to applications to a pixel circuit for an AMOLED TV etc.

[0007] The voltage-type pixel circuit mainly includes a switching Thin Film Transistor (TFT), a capacitor, and a driving TFT. The switching TFT charges a voltage corresponding to a data signal to the capacitor in response to a scan pulse, and the driving TFT controls the amount of current flowing into a light emitting element according to the magnitude of the voltage charged to the capacitor, thereby adjusting luminance of the light emitting element. Generally, luminous intensity of the light emitting element is proportional to the current supplied from the driving TFT.

[0008] However, a conventional voltage-type pixel circuit has non-uniform luminance due to non-constant threshold voltages V_{th} of driving TFTs according to position because of deviation in a manufacturing process etc. or has a short lifetime due to a reduction of luminance by varied threshold voltages over time. To solve such a problem, the voltage-type pixel circuit uses a method for detecting and compensating for the threshold voltage of the driving TFT.

[0009] A conventional voltage compensation type pixel circuit, which is disclosed, for example, in U.S. Pat. No. 7,649,202 (Korean Patent No. 10-0636483), detects, as a threshold voltage of a driving TFT, a source-gate voltage at which a drain-source current becomes sufficiently small by connecting the gate and the drain, and compensates a data voltage by the detected threshold voltage. The conventional voltage compensation type pixel circuit uses a control TFT serially connected between the driving TFT and a light emitting element in order to cut off light emission of the light emitting

element upon detecting the threshold voltage. However, the conventional voltage compensation type pixel circuit is problematic as follows.

[0010] First, when a pixel circuit using n-type TFTs detects a threshold voltage of a driving TFT of a diode structure, it cannot detect a negative threshold voltage of the driving TFT. Further, a pixel circuit using p-type TFTs cannot detect a positive threshold voltage of the driving TFT. This is because, in the driving TFT of a diode structure in which the gate and the drain thereof are connected to each other, a gate-drain voltage is 0V and thus a minimum or maximum detectable threshold voltage is limited to 0V.

[0011] Second, since the light emitting control TFT serially connected between the driving TFT and the light emitting element always operates in a linear region during light emission, it is greatly affected by bias stress and is greatly subjected to degradation. Generally, if a value obtained by subtracting a threshold value V_{th} from a gate-source voltage V_{gs} of a TFT is equal to or less than a drain-source voltage V_{ds} of the TFT (i.e. $V_{gs} - V_{th} \leq V_{ds}$), then the TFT is in a saturation region, and if a value obtained by subtracting the threshold value V_{th} from the gate-source voltage V_{gs} of the TFT is greater than or equal to the drain-source voltage V_{ds} of the TFT (i.e. $V_{gs} - V_{th} \geq V_{ds}$), then the TFT is in a linear region. It is known that TFT degradation progresses rapidly in the linear region. However, in the conventional voltage compensation type pixel circuit, the light emitting control TFT operates in the linear region and the driving TFT operates in the saturation region, during a light emitting period. Accordingly, the light emitting control TFT is subjected to degradation faster than the driving TFT due to bias stress.

[0012] Meanwhile, if the light emitting control TFT is omitted in order to solve such a problem thereof, since the light emitting element emits light even during a non-light emitting period, black luminance is increased and thus contrast is lowered.

[0013] As a known prior art document related to the invention of the present application, for example, we note Korean Patent No. 10-0636483 (U.S. Pat. No. 7,649,202).

BRIEF SUMMARY

[0014] A voltage compensation type pixel circuit of an organic light emitting diode for driving a light emitting element includes a driving transistor serially connected to the light emitting element between a high-potential power line and a low-potential power line to drive the light emitting element in response to a voltage supplied to a first node, a first program transistor for supplying a data voltage of a data line to a second node in response to a scan signal of a scan line, a second program transistor for supplying a reference voltage from a reference voltage supply line to the first node in response to the scan signal of the scan line, a merge transistor for connecting the first node and the second node in response to a merge signal of a merge line, a storage capacitor connected between a third node and the second node to store a voltage which corresponds to the data voltage in which the threshold voltage is compensated, wherein the third and second nodes are interposed between the driving transistor and the light emitting element, and first and second reset transistors for initializing at least two of the first, second, and third nodes to an initialization voltage of an initialization voltage line in response to a reset signal of a reset line.

[0015] In another aspect of the present disclosure, a voltage compensation type pixel circuit of an organic light emitting

diode for driving a light emitting element includes a driving transistor serially connected to the light emitting element between a high-potential power line and a low-potential power line to drive the light emitting element in response to a voltage supplied to a first node, a program transistor for supplying a data voltage of a data line to a second node in response to a scan signal of a scan line, a merge transistor for connecting the first node and the second node in response to a merge signal of a merge line, a storage capacitor connected between a third node and the second node to store a voltage which corresponds to the data voltage in which the threshold voltage is compensated, wherein the third and second nodes are interposed between the driving transistor and the light emitting element, first and second reset transistors for initializing at least two of the first, second, and third nodes to an initialization voltage of an initialization voltage line in response to a reset signal of a reset line, and a capacitor connected between the scan line and the first node to supply a reference voltage to the first node according to variation of the scan signal.

[0016] It is to be understood that both the foregoing general description and the following detailed description of the present invention are exemplary and explanatory and are intended to provide further explanation of the invention as claimed.

BRIEF DESCRIPTION OF THE DRAWINGS

[0017] The accompanying drawings, which are included to provide a further understanding of the invention and are incorporated in and constitute a part of this application, illustrate embodiment(s) of the invention and together with the description serve to explain the principle of the invention. In the drawings:

[0018] FIG. 1 is an equivalent circuit diagram of a pixel circuit of an AMOLED display device according to a first exemplary embodiment of the present invention;

[0019] FIG. 2 is a driving waveform chart of the pixel circuit of FIG. 1;

[0020] FIG. 3 is an equivalent circuit diagram of the pixel circuit of FIG. 1 illustrating a driving state during an initialization period;

[0021] FIG. 4 is an equivalent circuit diagram of the pixel circuit of FIG. 1 illustrating a driving state during a program period;

[0022] FIG. 5 is an equivalent circuit diagram of the pixel circuit of FIG. 1 illustrating a driving state during a light emitting period;

[0023] FIG. 6 is an equivalent circuit diagram of the pixel circuit of FIG. 1 to which p-type TFTs are applied;

[0024] FIG. 7 is a waveform chart illustrating driving of the pixel circuit of FIG. 6;

[0025] FIG. 8 is an equivalent circuit diagram of a pixel circuit of an AMOLED display device according to a second exemplary embodiment of the present invention;

[0026] FIG. 9 is an equivalent circuit diagram of a pixel circuit of an AMOLED display device according to a third exemplary embodiment of the present invention;

[0027] FIG. 10 is an equivalent circuit diagram of a pixel circuit of an AMOLED display device according to a fourth exemplary embodiment of the present invention;

[0028] FIG. 11 is an equivalent circuit diagram of a pixel circuit of an AMOLED display device according to a fifth exemplary embodiment of the present invention;

[0029] FIG. 12 is a driving waveform chart of the pixel circuit of FIG. 11; and

[0030] FIG. 13 is an equivalent circuit diagram of a pixel circuit of an AMOLED display device according to a sixth exemplary embodiment of the present invention.

DETAILED DESCRIPTION OF THE DRAWINGS AND THE PRESENTLY PREFERRED EMBODIMENTS

[0031] Reference will now be made in detail to the preferred embodiments of the present invention, examples of which are illustrated in the accompanying drawings. Wherever possible, the same reference numbers will be used throughout the drawings to refer to the same or like parts.

[0032] FIG. 1 is an equivalent circuit diagram of a pixel circuit of an AMOLED display device according to a first exemplary embodiment of the present invention, and FIG. 2 is a driving waveform chart of the pixel circuit of FIG. 1.

[0033] The pixel circuit of FIG. 1 drives an OLED to generate luminance corresponding to a data voltage V_{data} and includes 6 n-type TFTs and one storage capacitor C_s . A plurality of pixel circuits constitutes the AMOLED display device and each pixel circuit independently drives each OLED.

[0034] The OLED is serially connected to a driving TFT T_d between a high-potential power line **40** and a low-potential power line **42**. The OLED has an anode connected to the driving TFT T_d , a cathode connected to the low-potential power line **42**, and a light emitting layer between the cathode and the anode. The light emitting layer includes an electron injection layer, an electron transport layer, an organic light emitting layer, a hole transport layer, and a hole injection layer which are sequentially deposited between the cathode and the anode thereof. If a positive bias is supplied between the anode and cathode of the OLED, electrons are supplied from the cathode to the organic light emitting layer via the electron injection layer and the electron transport layer, and holes are supplied from the anode to the organic light emitting layer via the hole injection layer and the hole transport layer. The organic light emitting layer generates luminance proportional to current density by emitting light through a fluorescent or phosphorescent material by recombination of the supplied electrons and holes. Meanwhile, if a negative bias is supplied to the OLED, the OLED serves as a capacitor C_{oled} for accumulating charges.

[0035] The pixel circuit includes 6 n-type TFTs including one driving TFT T_d , two reset TFTs T_{res1} and T_{res2} , two program TFTs (i.e. one reference TFT T_{ref} and one data TFT T_{data}), and one merge TFT T_{me} for initializing light emission and includes one storage capacitor C_s connected between the OLED and the data TFT T_{data} .

[0036] The pixel circuit also includes three control lines, including an n-th (where n is a positive integer) scan line **30n** for supplying an n-th scan signal S_{Sn} , an n-th merge line **34n** for supplying an n-th merge signal M_{Sn} , and an n-th reset line **36n** for supplying an n-th reset signal R_{Sn} . The n-th reset line **36n** may be replaced with an (n-1)-th scan line **30n-1** which is a previous stage scan line of the n-th scan line **30n**. The n-th merge signal M_{Sn} has polarity opposite to the n-th scan signal S_{Sn} .

[0037] The pixel circuit includes three fixed power lines, including the high-potential power line **40** for supplying a high potential voltage V_{dd} , the low-potential power line **42** for supplying a low potential voltage V_{ss} lower than the high

potential voltage Vdd, and a reference voltage line 44 for supplying a reference voltage Vref which is lower than the high potential voltage Vdd and is higher than or equal to the low potential voltage Vss. The reference voltage Vref may be replaced with the low potential voltage Vss.

[0038] The pixel circuit also includes a data line 32 for supplying the data voltage Vdata and an initialization line 38 for supplying an initialization voltage Vini. Since the initialization voltage Vini does not need to be a fixed voltage, the initialization line 38 may be replaced with an (n-1)-th merge line 34n-1 which is a previous stage merge line. The initialization voltage Vini uses a voltage lower than the low potential voltage Vss, for example, a gate-off voltage Voff supplied to the (n-1)-th merge line 34n-1.

[0039] The reference TFT Tref has a gate electrode connected to the n-th scan line 30n, a first electrode connected to the reference voltage line 44, and a second electrode connected to a first node N1 which is connected to a gate electrode of the driving TFT Td. The first electrode and second electrode of the reference TFT Tref correspond to a source electrode or a drain electrode according to current direction. The reference TFT Tref supplies the reference voltage Vref to the first node N1 during a program period in response to the scan signal SSn from the n-th scan line 30n.

[0040] The data TFT Tdata has a gate electrode connected to the n-th scan line 30n, a first electrode connected to the data line 32, and a second electrode connected to a second node N2 which is connected to the storage capacitor Cs. The first electrode and second electrode of the data TFT Tdata correspond to a source electrode or a drain electrode according to current direction. The data TFT Tdata supplies the data voltage Vdata to the second node N2 during a program period in response to the scan signal SSn from the n-th scan line 30n.

[0041] The merge TFT Tme has a gate electrode connected to the n-th merge line 34n, a first electrode connected to the first node N1, and a second electrode connected to the second node N2. The first electrode and second electrode of the merge TFT Tme correspond to a source electrode or a drain electrode according to current direction. The merge TFT Tme connects the first node N1 and the second node N2 during an initialization period and a light emitting period in response to the merge signal MSn from the n-th merge line 34n.

[0042] The first reset TFT Tres1 has a gate electrode connected to the n-th reset line 36n, a first electrode connected to a third node N3 which is connected to the anode of the OLED, and a second electrode connected to the first node N1.

[0043] The second reset TFT Tres2 has a gate electrode connected to the n-th reset line 36n, a first electrode connected to the initialization line 38, and a second electrode connected to the third node N3. The first electrodes and second electrodes of the first and second reset TFTs Tres1 and Tres2 correspond to source electrodes or drain electrodes according to current direction. The first and second reset TFTs Tres1 and Tres2 initialize the nodes N1, N2, and N3 to the initialization voltage Vini during an initialization period in response to the reset signal RSn of the n-th reset line 36n. Using the (n-1)-th scan line 30n-1 as the n-th reset line 36n, the first and second reset TFTs Tres1 and Tres2 may be switched in response to a scan signal SSn-1 of the (n-1)-th scan line 30n-1 during the initialization period. Using the (n-1)-th merge line 34n-1 as the initialization line 38, the gate-off voltage Voff of a merge signal MSn-supplied to the (n-1)-th merge line 34n-1 may be supplied as the initialization voltage Vini during the initialization period.

[0044] The driving TFT Td has a gate electrode connected to the first node N1, a first electrode connected to the high-potential power line 40, and a second electrode connected to the third node N3 which is connected to the anode of the OLED. The first electrode and second electrode of the driving TFT Td correspond to a source electrode or a drain electrode according to current direction. The driving TFT Td drives the OLED by controlling current flowing into the OLED via the third node N3 from the high-potential power line 40 according to a voltage supplied to the first node N1.

[0045] The above-described pixel circuit is sequentially driven through an initialization period, a program period, and a light emitting period, as shown in FIG. 2. During the initialization period, the first, second, and third nodes N1, N2, and N3 are initialized to the initialization voltage Vini by active driving of the first and second reset TFTs Tres1 and Tres2 and the merge TFT Tme. During the program period, a threshold voltage Vth of the driving TFT Td is detected and a voltage corresponding to the data voltage Vdata in which the threshold voltage Vth is compensated is stored in the storage capacitor Cs, by active driving of the reference TFT Tref, the data TFT Tdata, and the driving TFT Td. During the light emitting period, the driving TFT Td drives the OLED to emit light in response to a voltage supplied from the storage capacitor Cs by active driving of the merge TFT Tme and the driving TFT Td.

[0046] FIGS. 3, 4, and 5 are equivalent circuit diagrams of the pixel circuit of FIG. 1 illustrating driving states during an initialization period, a program period, and a light emitting period respectively. Hereinafter, operation of the pixel circuit 20 during the initialization period, program period, and light emitting period will be described in detail with reference to FIGS. 2 to 5.

[0047] Since the pixel circuit of FIG. 1 is comprised of n-type TFTs, the TFTs are turned on and activated by a gate high voltage Vgh of a high state shown in FIG. 2, that is, a gate-on voltage Von and are turned off by a gate low voltage Vgl of a low state, that is, a gate-off voltage Voff.

[0048] During the initialization period shown in FIGS. 2 and 3, the first and second reset TFTs Tres1 and Tres2 and the merge TFT Tme are turned on to initialize the first to third nodes N1, N2, and N3 to the initialization voltage Vini. To this end, the gate-on voltage Von of the reset signal RSn is supplied to the n-th reset line 36n, the gate-on voltage Von of the merge signal MSn is supplied to the n-th merge line 34n, and the gate-off voltage Voff of the scan signal SSn is supplied to the n-th scan line. Then, as shown in FIG. 3, the first reset TFT Tres1, the second reset TFT Tres2, and the merge TFT Tme are turned on in response to the gate-on voltage Von, the reference TFT Tref and the data TFT Tdata are turned off in response to the gate-off voltage Voff, and the driving TFT Td is turned off by the initialization voltage Vini of a low state supplied to the first node N1. Accordingly, the initialization voltage Vini supplied to the initialization line 38 is supplied to the first, second, and third nodes N1, N2, and N3 via the turned-on first reset TFT Tres1, second reset TFT Tres2, and merge TFT Tme so that the first, second, and third nodes N1, N2, and N3 are initialized to the same initialization voltage Vini. A voltage of a low state lower than the low potential voltage Vss is supplied as the initialization voltage Vini. For example, the gate-off voltage Voff of the (n-1)-th merge signal MSn-1 may be supplied as the initialization voltage Vini by using the (n-1)-th merge line 34n-1 as the initialization line 38. As a result, during the initialization period, the

initialization voltage V_{ini} lower than the low potential voltage V_{ss} is supplied to the third node N3 and thus a negative bias is applied to the OLED. Therefore, the OLED does not emit light and serves as the capacitor Coled for accumulating charges. As the n-th reset line $36n$, the (n-1)-th scan line $30n-1$ for supplying the scan signal $SSn-1$ of the gate-on voltage V_{on} during the initialization period may be used.

[0049] Meanwhile, during the initialization period, in order to prevent unnecessary light emission of the OLED, an active period of the reset signal RSn during which the gate-on voltage V_{on} is supplied to the reset line $36n$ is set to be shorter than a period during which the initialization voltage of a low state ($V_{ini}=V_{off}$) is supplied as shown in FIG. 2. That is, an active period of the (n-1)-th scan signal $SSn-1$ during which the gate-on voltage is supplied to the (n-1)-th scan line $30n-1$ is set to be shorter than a non-active period within the non-active period of the merge signal $MSn-1$ during which the gate-off voltage V_{off} is supplied to the (n-1)-th merge line $34n-1$.

[0050] During the program period shown in FIGS. 2 and 4, the reference TFT $Tref$, the data TFT $Tdata$, and the driving TFT Td are turned on, the threshold voltage V_{th} of the driving TFT Td is detected by using the OLED as the capacitor Coled, and a voltage corresponding to the data voltage V_{data} in which the threshold voltage is compensated is stored in the storage capacitor Cs . To this end, the gate-on voltage of the scan signal SSn is supplied to the n-th scan line $30n$, the gate-off voltage V_{off} of the merge signal MSn is supplied to the n-th merge line $34n$, and the gate-off voltage V_{off} of the reset signal RSn is supplied to the n-th reset line $36n$. Then, as shown in FIG. 4, the reference TFT $Tref$ and the data TFT $Tdata$ are turned on in response to the gate-on voltage, the driving TFT Td is turned on until source-drain current becomes sufficiently small by the reference voltage V_{ref} supplied to the first node N1, and the first and second reset TFTs $Tres1$ and $Tres2$ and the merge TFT Tme are turned off by the gate-off voltage. If the data voltage V_{data} is supplied through the turned-on data TFT $Tdata$, a voltage of the second node N2 varies to the data voltage V_{data} from the initialization voltage ($V_{ini}=V_{off}$), and a voltage V_{N3} of the third node N3 varies as indicated in the following Equation 1 in proportion to a variation ($V_{data}-V_{off}$) of the voltage of the second node N2.

$$V_{N3} - V_{ini} + (V_{data} - V_{ini})S\left(\frac{c_s}{c_{oled} + c_s}\right) \quad [Equation 1]$$

[0051] Since the voltage V_{N3} of the third node N3 is lower than the low potential voltage V_{ss} , the OLED serves as the capacitor Coled due to the negative bias applied thereto. The OLED serving as the capacitor Coled accumulates charges through the driving TFT Td until a potential of the third node N3 reaches a value ($V_{ref}-V_{th}$) obtained by subtracting the threshold voltage V_{th} of the driving TFT Td from the reference voltage V_{ref} , that is, until the source-drain current I_{ds} of the driving TFT Td becomes sufficiently small. Then the voltage ($V_{ref}-V_{th}$) obtained by subtracting the threshold voltage V_{th} of the driving TFT Td from the reference voltage V_{ref} , that is, the threshold voltage V_{th} of the driving TFT Td can be detected in the third node N3. Especially, since the threshold voltage V_{th} is detected using the OLED as the capacitor without using a diode structure in which the gate and drain of the driving TFT Td are connected, a negative threshold voltage as well as a positive threshold voltage can

be accurately detected. As a result, the storage capacitor Cs stores a voltage ($V_{data}-V_{ref}+V_{th}$) corresponding to a difference between the data voltage V_{data} supplied via the turned-on data TFT $Tdata$ and the voltage ($V_{ref}-V_{th}$) supplied to the node N3. Namely, the storage capacitor Cs stores the voltage ($V_{data}-V_{ref}+V_{th}$) corresponding to the data voltage in which the threshold voltage V_{th} is compensated.

[0052] Meanwhile, in FIG. 2, an active period of the scan signal SSn supplied to the n-th scan line $30n$ is set to be shorter than a non-active period of the merge signal MSn supplied to the n-th merge line 34 . The (n-1)-th scan line $30n-1$ supplying the scan signal $SSn-1$ of the gate-off voltage V_{off} during the program period may be used as the n-th reset line $36n$.

[0053] During the light emitting period shown in FIGS. 2 and 5, the merge TFT Tme is turned on and the driving TFT Td drives the OLED to emit light in response to a voltage of the storage capacitor Cs . To this end, the gate-on voltage V_{on} of the merge signal MSn is supplied to the n-th merge line $34n$, the gate-off voltage V_{off} of the reset signal RSn is supplied to the n-th reset line $36n$, and the gate-off voltage V_{off} of the scan signal SSn is supplied to the n-th scan line $30n$. Then, as shown in FIG. 5, the merge TFT Tme is turned on in response to the gate-on voltage V_{on} to connect the first and second nodes N1 and N2, and the first reset TFT $Tres1$, the second reset $Tres2$, the reference TFT $Tref$ and the data TFT $Tdata$ are turned off in response to the gate-off voltage V_{off} . The driving TFT Td drives the OLED to emit light by controlling the current I_{ds} supplied to the OLED from the high potential voltage line 40 in response to the voltage ($V_{data}-V_{ref}+V_{th}$) of the storage capacitor Cs supplied to the node N1 via the merge TFT Tme . The OLED emits light in proportion to density of the output current I_{ds} of the driving TFT Td . The current I_{ds} supplied to the OLED through the TFT Td may be indicated by the following Equation 2.

$$I_{ds} = \frac{\beta}{2}S(V_{gs} - V_{th})^2 - \frac{\beta}{2}S[(V_{data} - V_{ref} + V_{th}) - V_{th}]^2 = \frac{\beta}{2}S(V_{data} - V_{ref})^2 \quad [Equation 2]$$

[0054] In Equation 2, β is a proportion coefficient determined by the structure (channel width and length) and physical properties of the driving TFT Td . Referring to Equation 2, since the threshold voltage V_{th} is offset in a voltage for determining the output current I_{ds} of the driving TFT Td , the output current I_{ds} is not influenced by the threshold voltage V_{th} of the driving TFT Td . In addition, since the output current I_{ds} is proportional to a voltage $V_{data}-V_{ref}$ corresponding to a difference between the data voltage V_{data} and the reference voltage V_{ref} , black luminance of the OLED may be controlled by adjusting the reference voltage V_{ref} . During the light emitting period, since the driving TFT Td always operates in a saturation region in which a value obtained by subtracting the threshold voltage V_{th} from the gate-source voltage V_{gs} is less than or equal to the drain-source voltage, that is, $V_{gs}-V_{th} \leq V_{ds}$, degradation of the driving TFT Td caused by bias stress is very small.

[0055] FIG. 6 is an equivalent circuit diagram of the pixel circuit of FIG. 1 to which p-type TFTs are applied, and FIG. 7 is a waveform chart illustrating driving of the pixel circuit of FIG. 6.

[0056] The pixel circuit of FIG. 1 is comprised only of n-type TFTs. However, p-type TFTs may be applied to the

pixel circuit as shown in FIG. 6. When comparing the pixel circuit of FIG. 6 with the pixel circuit of FIG. 1, a driving TFT Td, a first reset TFT Tres1 for controlling the driving TFT Td, a second reset TFT Tres2, a merge TFT Tme, a reference TFT Tref, and a data Tdata are comprised of p-type TFTs, an OLED has a reverse connection structure in which an anode thereof is connected to a high-potential power line 40 and a cathode thereof is connected to a third node N3 which is connected to the driving TFT Td, and a source electrode of the driving TFT Td is connected to a low-potential power line 42. Description of parts which are identical to those of FIG. 1 will be omitted.

[0057] Since the pixel circuit of FIG. 6 is comprised of P-type TFTs, the driving waveform shown in FIG. 7 has polarity opposite to the driving waveform of the n-type TFTs shown in FIG. 2. That is, in the driving waveform shown in FIG. 7, a gate-low voltage Vgl of a low state is used as a gate-on voltage, and a gate-high voltage Vgh of a high state is used as a gate-off voltage.

[0058] During an initialization period shown in FIG. 7, the first reset TFT Tres1, the second reset TFT Tres2, and the merge TFT Tme are turned on in response to the gate-on voltage Von of an n-th reset signal RSn and an n-th merge signals MSn to initialize first, second, and third nodes N1, N2, and N3 to an initialization voltage (Vini=Voff=Vgh>Vss). In this case, the OLED is not driven by a negative bias and, instead, serves as a capacitor Coled.

[0059] During a program period shown in FIG. 7, the reference TFT Tref and the data TFT Tdata are turned on in response to the gate-on voltage of an n-th scan signal SSn, and the driving TFT Td is turned on until source-drain current thereof becomes sufficiently small in response to a reference voltage Vref. Therefore, a threshold voltage Vth of the driving TFT Td is detected by using the OLED as the capacitor and a storage capacitor Cs stores a voltage (Vdata-Vref+Vth) corresponding to a data voltage Vdata in which the threshold voltage Vth is compensated. In this case, since the driving TFT is not a diode structure in which a gate and drain thereof are connected, a positive threshold voltage of the p-type driving TFT Td as well as a negative threshold voltage can be accurately detected.

[0060] During a light emitting period shown in FIG. 7, the merge TFT Tme is turned on in response to the gate-on voltage Von of the n-th merge signal MSn, and the driving TFT Td drives the OLED to emit light in response to the voltage (Vdata-Vref+Vth) supplied to the node N2 from the storage capacitor Cs through the merge TFT Tme. Since the driving TFT Td operates only in a saturation region, degradation of the driving TFT Td caused by bias stress is very small.

[0061] FIG. 8 is an equivalent circuit diagram of a pixel circuit of an AMOLED display device according to a second exemplary embodiment of the present invention.

[0062] The pixel circuit of FIG. 8 according to the second embodiment is the same as the pixel circuit of FIG. 1 according to the first embodiment, except that the second electrode of the first reset TFT Tres1 is connected not to the first node N1 but to the second node N2 and, therefore, description of parts which are identical to those of FIG. 1 will be omitted. In the pixel circuit of FIG. 8, during an initialization period, the first and second reset TFTs Tres1 and Tres2 and the merge TFT Tme are turned on by the gate-on voltage Von of the reset

signal RSn and the merge signal MSn to initialize the first, second, and third nodes N1, N2, and N3 to the initialization voltage Vini.

[0063] FIG. 9 is an equivalent circuit diagram of a pixel circuit of an AMOLED display device according to a third exemplary embodiment of the present invention.

[0064] The pixel circuit of FIG. 9 according to the third embodiment is the same as the pixel circuit of FIG. 1 according to the first embodiment, except that the second electrode of the first reset TFT Tres1 is connected not to the first node N1 but to the second node N2, and the second electrode of the second reset TFT Tres2 is connected not to the third node N3 but to the second node N2. Therefore, description of parts which are identical to those of FIG. 1 will be omitted. In the pixel circuit of FIG. 9, during an initialization period, the first and second reset TFTs Tres1 and Tres2 and the merge TFT Tme are turned on by the gate-on voltage Von of the reset signal RSn and the merge signal MSn to initialize the first, second, and third nodes N1, N2, and N3 to the initialization voltage Vini.

[0065] FIG. 10 is an equivalent circuit diagram of a pixel circuit of an AMOLED display device according to a fourth exemplary embodiment of the present invention.

[0066] The pixel circuit of FIG. 10 according to the fourth embodiment is the same as the pixel circuit of FIG. 1 according to the first embodiment, except that the second electrode of the first reset TFT Tres1 is connected not to the first node N1 but to the second node N2, and the second electrode of the second reset TFT Tres2 is connected not to the third node N3 but to the first node N1. Therefore, description of parts which are identical to those of FIG. 1 will be omitted. In the pixel circuit of FIG. 10, during an initialization period, the first and second reset TFTs Tres1 and Tres2 and the merge TFT Tme are turned on by the gate-on voltage Von of the reset signal RSn and the merge signal MSn to initialize the first, second, and third nodes N1, N2, and N3 to the initialization voltage Vini.

[0067] FIG. 11 is an equivalent circuit diagram of a pixel circuit of an AMOLED display device according to a fifth exemplary embodiment of the present invention, and FIG. 12 is a driving waveform chart of the pixel circuit of FIG. 11.

[0068] The pixel circuit of FIG. 10 according to the fifth embodiment is the same as the pixel circuit of FIG. 1 according to the first embodiment, except that a third reset TFT Tres3 is additionally included, and therefore, description of parts which are identical to those of FIG. 1 will be omitted. The third reset TFT Tres3 has a gate electrode connected to the n-th reset line 36n, a first electrode connected to the high-potential power line 40, and a second electrode connected to the second node N2. The first electrode and the second electrode of the third reset TFT Tres3 correspond to a source electrode or a drain electrode according to current direction. The third reset TFT Tres3 initializes the second node N2 to the high potential voltage Vdd during an initialization period in response to the reset signal RSn supplied to the n-th reset line 36n or the gate-on voltage Von of the scan signal SSn-1 supplied to the (n-1)-th scan line 30n-1.

[0069] When comparing the driving waveforms shown in FIG. 2 with the driving waveforms shown in FIG. 12, the merge signal MSn supplied to the n-th merge line 34n applies the gate-off voltage Voff only during the program period in FIG. 2 while the merge signal MSn supplied to the n-th merge line 34n applies the gate-off voltage Voff during both the initialization period and the program period in FIG. 12. Fur-

ther, in FIG. 2, the gate-off voltage V_{off} of the previous stage $(n-1)$ -th merge signal MS_{n-1} is used as the initialization voltage V_{ini} while in FIG. 12, the initialization voltage V_{ini} is fixed to a DC voltage.

[0070] During the initialization period shown in FIG. 12, the first and second reset TFTs T_{res1} and T_{res2} initialize the first and third nodes $N1$ and $N3$ to the initialization voltage V_{ini} in response to the reset signal RS_n supplied to the n -th reset line 36_n or the gate-on voltage V_{on} of the scan signal SS_{n-1} supplied to the $(n-1)$ -th scan line 30_{n-1} . The third reset TFT T_{res3} initializes the second node $N2$ to the high potential voltage V_{dd} . The merge TFT T_{me} is turned off in response to the gate-off voltage V_{off} of the merge signal MS_n supplied to the n -th merge line 34_n .

[0071] During the program period shown in FIG. 12, the reference TFT T_{ref} supplies the reference voltage V_{ref} to the first node $N1$ in response to the gate-on voltage V_{on} of the scan signal SS_n supplied to the n -th scan line 30_n , and the data TFT T_{data} supplies the data voltage V_{data} to the second node $N2$. If the data voltage V_{data} is supplied through the turned-on data TFT T_{data} , a voltage of the second node $N2$ varies from the high potential voltage V_{dd} to the data voltage V_{data} , and a voltage of the third node $N3$ varies in proportion to a variation $V_{data}-V_{dd}$ of the voltage of the second node $N2$ as indicated by the following Equation 3.

$$V_{N3} = V_{ini} + (V_{data} - V_{dd})S\left(\frac{C_s}{C_{oled} + C_s}\right) \quad [Equation 3]$$

[0072] In this case, since the voltage V_{N3} of the third node $N3$ is lower than the low potential voltage V_{ss} , the OLED serving as the capacitor C_{oled} accumulates charges through the driving TFT T_d until a potential of the third node $N3$ is a value $(V_{ref}-V_{th})$ obtained by subtracting the threshold voltage V_{th} of the driving TFT T_d from the reference voltage V_{ref} , that is, the output current I_{ds} of the driving TFT T_d is sufficiently small. As a result, the storage capacitor C_s stores a voltage $(V_{data}-V_{ref}+V_{th})$ corresponding to a difference between the data voltage V_{data} supplied via the turned-on data TFT T_{data} and the voltage $(V_{ref}-V_{th})$ supplied to the third node $N3$, thereby storing the voltage $(V_{data}-V_{ref}+V_{th})$ corresponding to the data voltage V_{data} in which the threshold voltage V_{th} is compensated.

[0073] During a light emitting period shown in FIG. 12, the merge TFT T_{me} is turned on in response to the gate-on voltage of the merge signal MS_n supplied to the n -th merge line 34_n . The driving TFT T_d controls the source-drain current I_{ds} in response to the voltage $(V_{data}-V_{ref}+V_{th})$ of the storage capacitor C_s supplied to the first node $N1$ through the turned-on merge TFT T_{me} , thereby driving the OLED to emit light.

[0074] FIG. 13 is an equivalent circuit diagram of a pixel circuit of an AMOLED display device according to a sixth exemplary embodiment of the present invention.

[0075] The pixel circuit of FIG. 13 according to the sixth embodiment is the same as the pixel circuit of FIG. 1 according to the first embodiment, except that a capacitor C_d is used instead of the reference TFT T_{ref} and, therefore, description of parts which are identical to those of FIG. 1 will be omitted. The capacitor C_d is connected between the n -th scan line 30_n and the first node $N1$. If the n -th scan signal SS_n varies to the gate-on voltage V_{on} from the gate-off voltage V_{off} during the program period shown in FIG. 2, a voltage of the first node $N1$

increases in proportion to the product of the varied voltage of the n -th scan signal and a ratio C_d/C_{total} of a capacitance of the capacitor C_d to a total capacitance C_{total} including a parasitic capacitance. Thus, during a program period, the capacitor C_d supplies a voltage similar to the reference voltage V_{ref} to the first node $N1$, like the reference TFT T_{ref} of FIG. 1, to drive the driving TFT T_d until the source-drain current I_{ds} of the driving TFT T_d is sufficiently small, so that the threshold voltage V_{th} can be detected.

[0076] As described above, the voltage compensation type pixel circuit of the AMOLED display device according to the present invention detects the threshold voltage V_{th} using the OLED as the capacitor C_{oled} without constructing the driving TFT T_d as a diode structure during a program period. Therefore, a negative threshold voltage as well as a positive threshold voltage can be detected irrespective of n-type TFTs and p-type TFTs, and thus the threshold voltage V_{th} can be accurately detected in a variety of voltage ranges.

[0077] The voltage compensation type pixel circuit of the AMOLED display device according to the present invention uses a connection structure in which the driving TFT T_d and the OLED are serially connected between the high-potential power line 40 and the low-potential power line 42 and uses the OLED as the capacitor C_{oled} by applying a negative bias to the OLED during an initialization period and a program period. Accordingly, unnecessary luminance is prevented by emitting the OLED only during a light emitting period and thus contrast can be raised.

[0078] The voltage compensation type pixel circuit of the AMOLED display device according to the present invention causes the driving TFT T_d to always operate in a saturation region during a light emitting period and thus TFT degradation caused by bias stress is small.

[0079] It will be apparent to those skilled in the art that various modifications and variations can be made in the present invention without departing from the spirit or scope of the inventions. Thus, it is intended that the present invention covers the modifications and variations of this invention provided they come within the scope of the appended claims and their equivalents.

1. A voltage compensation type pixel circuit of an organic light emitting diode for driving a light emitting element, comprising:

a driving transistor serially connected to the light emitting element between a high-potential power line and a low-potential power line to drive the light emitting element in response to a voltage supplied to a first node;

a program transistor that supplies a data voltage of a data line to a second node in response to a scan signal of a scan line;

a merge transistor that connects the first node and the second node in response to a merge signal of a merge line;

a storage capacitor connected between a third node and the second node to store a voltage which corresponds to the data voltage in which the threshold voltage is compensated, wherein the third and second nodes are interposed between the driving transistor and the light emitting element;

first and second reset transistors that initialize at least two of the first, second, and third nodes to an initialization voltage of an initialization voltage line in response to a reset signal of a reset line; and

a capacitor connected between the scan line and the first node to supply a reference voltage to the first node according to variation of the scan signal.

2. The voltage compensation type pixel circuit of claim 1, wherein a negative bias is applied to the light emitting element during the initialization period and the program period to use the light emitting element as the capacitor, and a positive bias is applied to the light emitting element only during the light emitting period to drive the light emitting element.

3. The voltage compensation type pixel circuit of claim 2, wherein, during the program period, the capacitor of the light emitting element accumulates charges through the driving transistor until a potential of the third node reaches a voltage corresponding to a difference between the reference voltage and the threshold voltage, and the storage capacitor stores a voltage corresponding to a difference between voltages of the second and third nodes, and

 during the light emitting period, the driving transistor supplies current proportional to the square of a voltage

$(V_{data} - V_{ref})$ corresponding to a difference between the data voltage and the reference voltage to the light emitting element.

4. The voltage compensation type pixel circuit of claim 2, wherein the transistors of the pixel circuit are n-type transistors and detect a positive threshold voltage or a negative threshold voltage during the program period.

5. The voltage compensation type pixel circuit of claim 2, wherein the transistors of the pixel circuit are p-type transistors and detect a positive threshold voltage or a negative threshold voltage during the program period.

6. The voltage compensation type pixel circuit of claim 2, wherein black luminance of the light emitting element is controlled by adjusting the reference voltage.

7. The voltage compensation type pixel circuit of claim 2, wherein the driving transistor is always driven in a saturation region.

* * * * *

专利名称(译)	有源矩阵有机发光二极管显示装置的电压补偿型像素电路		
公开(公告)号	US20130241916A1	公开(公告)日	2013-09-19
申请号	US13/889903	申请日	2013-05-08
[标]申请(专利权)人(译)	乐金显示有限公司		
申请(专利权)人(译)	LG DISPLAY CO. LTD.		
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IPC分类号	G09G3/32		
CPC分类号	G09G3/3233 G09G3/3291 G09G2310/0251 G09G2300/0861 H01L27/3244		
优先权	1020100046610 2010-05-18 KR		
其他公开文献	US8866705		
外部链接	Espacenet USPTO		

摘要(译)

AMOLED显示装置的电压补偿型像素电路包括驱动晶体管，该驱动晶体管串联连接到高电位和低电位电源线之间的发光元件，以响应于提供给第一节点的电压驱动发光元件，第一编程晶体管，用于响应于扫描线的扫描信号将数据线的数据电压提供给第二节点，第二编程晶体管，用于响应于第一节点从参考电压供应线向第一节点提供参考电压。扫描线的扫描信号，用于响应于合并线的合并信号连接第一和第二节点的合并晶体管，连接在第三节点和插入在驱动晶体管和发光元件之间的第二节点之间的存储电容器存储与阈值电压被补偿的数据电压相对应的电压，以及用于初始化的第一和第二复位晶体管响应于复位线的复位信号，第一，第二和第三节点中的至少两个节点到初始化电压线的初始化电压。

